

Erratum

Correction to “Influence of the Si Substrate on the Transport and Magnetotransport Properties of Nanostructured Fe-Ag Thin Films”

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We would like to make some corrections to the first two figures presented in our recent paper [1]. In Fig. 1, the numbers in the x-axis should be divided by 10^4 . Fig. 2 should be replaced by the following figure:

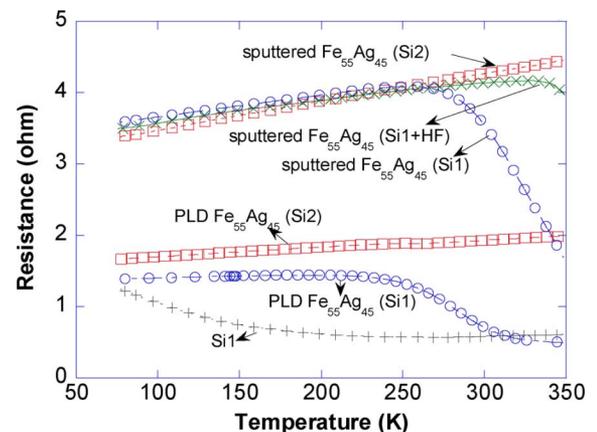


Fig. 2. Effective resistance as a function of temperature for a sputtered $\text{Fe}_{55}\text{Ag}_{45}$ thin film and a PLD $\text{Fe}_{55}\text{Ag}_{45}$ thin film, deposited onto both Si1 and Si2. The resistance curves corresponding to the Si1 substrate after being treated with HF and to the sputtered $\text{Fe}_{55}\text{Ag}_{45}$ thin film deposited onto these HF treated substrate (Si1 + HF) are also included for comparison.

REFERENCES

- [1] J. Alonso, I. Orue, M. L. Fdez-Gubieda, J. M. Barandiarán, J. Chaboy, L. Fernández Barquín, A. Svalov, and N. Kawamura, “Influence of the Si substrate on the transport and magnetotransport properties of nanostructured Fe-Ag thin films,” *IEEE Trans. Magn.*, vol. 44, no. 11, pp. 2784–2787, Nov. 2008.

Manuscript received April 23, 2009. Current version published August 19, 2009. Corresponding author: J. Alonso (e-mail: jalonsomasa@gmail.com).

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Digital Object Identifier 10.1109/TMAG.2009.2023211